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Front Matter: Volume 8564

, "Front Matter: Volume 8564," Proc. SPIE 8564, Nanophotonics and Micro/
Nano Optics, 856401 (7 January 2013); doi: 10.1117/12.2017920

SPIE.

Event: Photonics Asia, 2012, Beijing, China

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Nanophotonics and Micro/Nano Optics

**Zhiping Zhou
Kazumi Wada**
Editors

**5–7 November 2012
Beijing, China**

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SPIE

Volume 8564

Proceedings of SPIE 0277-786X, V.8564

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

Nanophotonics and Micro/Nano Optics, edited by Zhiping Zhou, Kazumi Wada, Proc. of SPIE Vol. 8564, 856401
© 2012 SPIE · CCC code: 0277-786/12/\$18 · doi: 10.1117/12.2017920

Proc. of SPIE Vol. 8564 856401-1

The papers included in this volume were part of the technical conference cited on the cover and title page. Papers were selected and subject to review by the editors and conference program committee. Some conference presentations may not be available for publication. The papers published in these proceedings reflect the work and thoughts of the authors and are published herein as submitted. The publisher is not responsible for the validity of the information or for any outcomes resulting from reliance thereon.

Please use the following format to cite material from this book:

Author(s), "Title of Paper," in *Nanophotonics and Micro/Nano Optics*, edited by Zhiping Zhou, Kazumi Wada, Proceedings of SPIE Vol. 8564 (SPIE, Bellingham, WA, 2012) Article CID Number.

ISSN: 0277-786X

ISBN: 9780819493194

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA

Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445

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